

Fig 1. The Rectangular ParallePiped (RPP) approach to Single-Event Effect (SEE) rate estimation fits the SEE cross section  $\sigma$  as a function of Linear Energy Transfer (LET) to a cumulative Weibull (or other) form. The fit is combined with radiation environment models assuming a simplified sensitive volume (SV=RPP) to estimate charge deposited in therein.



Variable Energy/LET

Fig. 2 After traversing nonuniform overburden, uniform energy/LET ion beams will have a range of energies and LET at the SV.

However, in many situations, LET of the ion that causes a given SEE is uncertain, including:

. Secondary ions from nuclear collisions in the die [1,2] or packaging [3].

2. Space environments [4].

3. Ion beams degraded by traversing nonuniform overburden-e. g. parts thinned for back-side irradiation [5] or packaged parts.

Situations where SV dimensions and ion energies render the concept of a single, welldefined LET problematic [6]

GLM extend likelihood methods

beyond linear probabilistic

models. The complex model

enters the GLM in terms of the

parameters of a probabilistic

models from the exponential

family—e.g. normal, Poisson

Likelihood allows one to find

not just the best-fit solution, but

also bounding fits for any

Selecting the fit within a given

CL contour that yields the

highest SEE rate gives the

bounding SEE rate consistent

with that confidence, e.g.

 $R_{CL=90\%}$  bounds the rate with at

least 90% confidence. The

ratio of  $R_{Cl=90\%}$  to the maximum

likelihood (ML) rate  $(R_{ML})$  is a

good metric for data quality.

(CL)

exponential, etc.

confidence level

LET uncertainties further complicate the difficult task of fitting  $\sigma$  vs. LET data. To date, attempts to deal with LET uncertainties have either limited the role of LET in the analysis[1,2,6] or assigned "representative" LET values for different cross sections [5]. This work instead broadens a Generalized Linear Model (GLM) fitting approach [7] to account for LET uncertainties.

## **GLMs and SEE Data Fitting**

Inputs = Direct Observables: { $LET_i$ }, {Fluence= $F(LET_i)$ }, {Counts= $N_O(LET_i)$ }

Device Response Model for Predicted Counts, N  $N_{P}(LET_{i}) = F(LET_{i}) * \sigma_{s} * Weibull(\Delta LET_{i}, w, s)$  $\Delta LET_i = LET_i - LET_o$ ,  $LET_o = Onset LET$  $\sigma_{\rm s}$  = Saturated Cross section w, s = Weibull width and shape

### **Statistical Model:**

Poisson( $N_{O}(LET_{i})$ ), Mean =  $N_{P}(LET_{i})$ ) Solve for *LET*<sub>0</sub>,  $\sigma_{sat}$ , *w*, *s* that maximize Likelihood,  $\Lambda$ 

 $\Lambda = \prod_{i=1}^{n} \text{Poisson}(N_{o}(LET_{i})), NP(\Delta LET_{i}))$ (1)

Also allows rate to be bounded for a fiven Confidence, Cl Determine confidence contours in  $LET_0$ ,  $\sigma_{sat}$ , w, s using

 $\frac{\Lambda(CL)}{\Lambda} = \exp(-0.5 * INV\chi^2 (1 - CL, DOF))$  (2)

(DOF=# parameters=4. Parameter set inside CL yielding Worst-Case (WC) rate is the bounding rate @ CL.

If LET for  $i^{th}$  run is uncertain, ranging  $L_i^l \leq LET_i \leq L_i^u$ , the ollowing changes needed to GLM: ) Must know distribution of ion fluence vs. LET,  $\Phi_{i}$ (LET)

?)  $N_o(i)$  is now equal to event count observed in  $i^{th}$  run and produced by  $\Phi i$ (LET)

3)  $N_p(i) = \int_{U}^{Lu} \Phi_i(LET) * \sigma_s * Weibull(\Delta LET_i, w, s) dLET$ 4) Continue w/ Poisson Likelihood as before.

To adapt the GLM to uncertain LET, we modify the equation for  $N_n$  by adding an integral over ion fluence vs. LET. The expression for  $N_p(i)$  in the lilac square is equivalent to multiplying the total ion fluence by the cross section averaged over the LET distribution. Since  $\Phi i(LET_i)$  can be written as the product of the total flux for ion *i*, *Ni*, and the probability distribution that the ion has a given LET value, the integral in 3) n in the lilac section is just the product of *Ni* and average cross section over the LET uncertainty range.

### Example: Backside Irradiation of an SDRAM

One common situation where ion LET uncertainty becomes significant arises due to the difficulty of achieving uniform overburden thickness when thinning a die for backside irradiation. We take as an example the use of a GLM to deal with LET uncertainty arising from backside irradiation of a DDR2 SDRAM [7]. Starting with figure 2 from [7], we estimated the proportion of the die falling into each 10micron thickness bin. Then, using a lookup table constructed using output from SRIM [8], transported representative ion beams from the 15 and 25 MeV/u tunes from the Texas A&M University Cyclotron Facility (TAMU) through these thicknesses to extract the LET distributions in Table I:

### TABLE I: LET DISTRIB

Thickness, μm	0	30-40	40-50	50-60	60-70	70-80	80-90	95-100					
Proportion of die	0	0.11	0.33	0.19	0.18	0.1	0.08	0.02					
LET After Overburden (MeVcm²/mg), TAMU 25 MeV Tune													
N@0 $^{\circ}$ to Normal	0.86	0.88	0.88	0.88	0.89	0.89	0.90	0.90					
N@45 $^{\circ}$ to Normal	1.22	1.25	1.25	1.26	1.27	1.28	1.29	1.30					
N@60 $^{\circ}$ to Normal	1.72	1.78	1.80	1.82	1.84	1.86	1.88	1.90					
Ne@0° to Normal	1.73	1.77	1.79	1.80	1.81	1.82	1.84	1.85					
Ne@45 $^{\circ}$ to Normal	2.45	2.53	2.55	2.58	2.61	2.64	2.68	2.71					
Ne@60° to Normal	3.47	3.63	3.69	3.75	3.81	3.88	3.94	4.01					
Ar@0 $^{\circ}$ to Normal	5.60	5.78	5.85	5.92	5.98	6.05	6.12	6.19					
Ar@45 $^{\circ}$ to Normal	7.92	8.31	8.45	8.59	8.72	8.86	9.04	9.22					
@Ar60° to Normal	11.19	12.04	12.31	12.60	12.96	13.32	13.69	14.13					
Xe@0 $^{\circ}$ to Normal	41.77	44.61	45.52	46.52	47.52	48.69	49.85	51.15					
Xe@45 $^{\circ}$ to Normal	59.07	65.02	67.02	69.31	71.75	74.48	77.57	81.02					
Xe@60 $^{\circ}$ to Normal	83.53	96.20	100.96	106.51	113.04	120.72	129.50	137.51					
Cu@0° to Normal	13.35	14.02	14.22	14.45	14.69	14.92	15.19	15.47					
Kr@0 $^{\circ}$ to Normal	20.03	21.22	21.61	22.04	22.48	22.95	23.46	23.99					
Ag@0 $^{\circ}$ to Normal	32.65	34.93	35.63	36.45	37.30	38.19	39.18	40.26					
LET After Overburden (MeVcm²/mg), TAMU 15 MeV Tune													
N@0° to Normal	1.32	1.38	1.40	1.42	1.44	1.46	1.49	1.51					
N@45° to Normal	1.87	1.99	2.03	2.08	2.13	2.18	2.23	2.29					
N@60°to Normal	2.64	2.91	3.00	3.10	3.21	3.35	3.49	3.66					
Ne@0 $^{\circ}$ to Normal	2.59	2.75	2.81	2.86	2.92	2.99	3.06	3.13					
Ne@45 $^{\circ}$ to Normal	3.66	4.01	4.12	4.25	4.39	4.55	4.73	4.92					
Ne@60°to Normal	5.18	5.91	6.18	6.50	6.86	7.31	7.84	8.52					
Ar@0 $^{\circ}$ to Normal	7.90	8.53	8.76	8.99	9.26	9.54	9.84	10.18					
Ar@45 $^{\circ}$ to Normal	11.17	12.54	13.03	13.60	14.24	15.00	15.90	16.99					
Ar@60°to Normal	15.79	18.80	20.01	21.54	23.53	26.17	30.02	35.86					
Cu@0 $^{\circ}$ to Normal	17.98	19.98	20.70	21.53	22.50	23.60	24.91	26.45					
Kr@0 $^{\circ}$ to Normal	26.66	29.69	30.71	31.82	33.07	34.39	35.83	37.34					
Ag@0°to Normal	42.34	47.89	49.90	52.12	54.49	56.92	58.89	59.04					
Xe@0°to Normal	53.14	59.20	61.27	63.47	65.72	67.82	69.21	68.67					
Ho@0°to Normal	69.90	75.52	77.29	79.06	80.71	81.93	82.15	80.05					
Au@0°to Normal	80.89	86.50	88.31	90.17	91.98	93.54	94.33	93.31					

Table I indicates that heavier the ion and the greater the angle of incidence to the normal, the greater the LET uncertainty introduced by nonuniform overburden. However, the behavior of ion flux vs. LET and the rapidity of the rise in cross section vs. LET over the range of LET uncertainty also affect the systematic error magnitude. Moreover, if the data leave important features of device response uncertain (e.g.  $\sigma_{sat}$ , LET<sub>0</sub>, etc.), the resulting uncertainty in these parameters car augment the systematic errors due to LET uncertainty. To explore these effects, we carried out Monte Carlo studies of the effect of LET uncertainty coupled with that of Poisson errors on the event counts over a range of Weibull fit parameters.

TABLE II: IONS USED VS. WEIBULL WIDTH, ENERGY

Ions Used Un MC Runs, 25 MeV Tune											
1	2	3	4	5	6	7					
Ν	Ne	Ne@45°	Ar	Ar=@45°	Cu	Xe					
Ν	Ne	Ar	Cu	Kr	Ag	Хе					
Ν	Ne	Ar	Kr	Xe	Xe=@45°	Xe=@60°					
Ions Used Un MC Runs, 15 MeV Tune											
Ν	N@45°	Ne	Ne@60°	Ar	Ar@60°	Хе					
Ν	Ne	Ar	Cu	Kr	Ag	Xe					
Ν	Ne	Ar	Kr	Xe	Но	Au					
	1 N N N N N	Ions   1 2   N Ne   N Ne   N Ne   Ions Ions   N N@45°   N Ne   N Ne	Ions Used Un123NNeNe@45°NNeArNNeArIons Used UnNNN@45°NeNNeArNNeArNNeAr	Ions Used Un MC Run1234NNeNe@45°ArNNeArCuNNeArKrIons Used Un MC RunNN@45°NeNe@60°NNeArCuNNeArKr	Ions Used Un MC Runs, 25 MeV       1     2     3     4     5       N     Ne     Ne@45°     Ar     Ar=@45°       N     Ne     Ar     Cu     Kr       N     Ne     Ar     Cu     Kr       N     Ne     Ar     Kr     Xe       Ions Used Un MC Runs, 15 MeV       N     N@45°     Ne     Ne@60°     Ar       N     Ne     Ar     Cu     Kr       N     Ne     Ar     Cu     Kr       N     Ne     Ar     Cu     Kr	Ions Used Un MC Runs, 25 MeV Tune     1   2   3   4   5   6     N   Ne   Ne@45°   Ar   Ar=@45°   Cu     N   Ne   Ar   Cu   Kr   Ag     N   Ne   Ar   Cu   Kr   Ag     N   Ne   Ar   Kr   Xe   Xe=@45°     N   N@45°   Ne   Ne@60°   Ar   Ar@60°     N   Ne   Ar   Cu   Kr   Ag     N   Ne   Ar   Cu   Kr   Ag     N   Ne   Ar   Cu   Kr   Ag     N   Ne   Ar   Cu   Kr   Ag					

# Dealing with Ion LET Uncertainties: An Application of Generalized Linear Models Ray Ladbury, NASA -GSFC code 561.4, Greenbelt, MD 20771.

Abstract: We propose Generalized Linear Models for understanding errors in SEE rate due to uncertainties in LET of the event. Applications are suggested and assessed for suitability of treatment by the model.

We chose the 8 ions for each of the runs such that the main features (e.g.  $\sigma_{sat}$ , LET<sub>0</sub> and the rising portion of the curve) of the Weibull form of the cross section were resolved. This meant that rapidly rising cross sections used mainly lower-LET ions and broad curves used more higher LET ions.



We began by exploring how Weibull width and ion energy affect systematic errors. Although we have discussed LET uncertainty in the context of backside irradiation We fixed  $\sigma_{sat}$ =.0005 cm<sup>2</sup>, LET<sub>0</sub>,=1 MeVcm<sup>2</sup>/mg and shape s=2. We then varied the of thinned microcircuits, it arises in many other situations. One important example Weibull width from narrow (w=5) to medium (w=20) and very slowly saturating occurs when irradiating packaged microcircuits with an ion beam sufficiently (w=80) forms, generating 1000 Monte Carlo events for each run. These runs show energetic to reach the sensitive volume that while SEE rates converge even for moderately low event counts, if LET volumes inside uncertainty is treated improperly, they will converge to the wrong value. Lead Frame complicated packages may covered by heat Heatsink



Fig. 3 Even for low event counts (2-16 pe cross section). the rate determined by the GLM fit converges on average to the value generated by the Monte Carlo as long as the uncertainty in LET is treated as outlined in section I. Usually, once event counts reac 16 or more, the statistical errors on the



Events per Cross Section Point Fig. 5 Systematic errors due to LET uncertainty are largely independent of random (Poisson) errors on event counts, as shown by this plot of COV versus event count. Similar behavior is

seen for other generating fit parameters The main concern when dealing with systematic errors is how large they can get. Fig. 7 illustrates that the magnitude of the errors discussed here is highest when an ion has a large LET uncertainty that overlaps with a region where  $\sigma$  vs. LET is rising rapidly and where the ion flux in the intended environment is not negligible.



Kr@45° Kr@60° Ag@0° Ag@45° Ag@60° Xe@0° Xe@45° Xe@60 Fig. 7 Broad Weibull forms (w=80) and higher LET0 increase the importance of high-LET ions, where LET uncertainty is higher. Larger Weibull shape s causes  $\sigma$  to rise rapidly at median LET values. In essence, the highest systematic errors (sometimes exceeding the magnitude of the rate) occur when rapid rise overlaps large uncertainty.

Although this analysis looked at only one example of LET uncertainty, the results suggest general principles useful for minimizing systematic errors due to LET uncertainties even when precise LET distributions cannot be determined:

- 1) If ion paths to device sensitive volumes traverse variable overburden, it is important to ensure they remain on the high-energy side of the Bragg peak so that systematic errors do not result in underestimation of error rates.
- Although higher-energy ions usually have lower LET uncertainty, if one must irradiate at angle to achieve sufficient effective LET to reveal  $\sigma_{sat}$ , the longer ion path lengths can result in higher LET uncertainty for the high-energy beam.
- 3) If critical features of the  $\sigma$  vs. LET curve—e.g. onset, saturation and steep rise with LET are not well defined in the data, the resulting uncertainty in fit parameters can augment the systematic errors due to LET uncertainty.

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Fig. 4 When LET is uncertain, assigning a since LET value for each cross section introduces a the correct value regardless of event count Because ion energies here remain on the high side of the Bragg peak, ions transiting overburden increases their LET, resulting in overestimated rates



xpected Events per Cross Section Point

Fig. 6 R<sub>CL=90%</sub> serves as a conservative bound on SEE rates. Usually,  $R_{CL=90\%}$  bounds the rea rate more than 90% of the time. Excess margin (defined in the graph) decreases with event count, but it remains greater than zero.



uncertainty treatment depend on the magnitude of the uncertainty, but also on how rapidly the cross section is rising and how rapidly the environmental ion flux is falling over that uncertainty. The influence of ions 1 and 2 is limited by the small change in cross section, of ion 4 due to the falling ion flux and ion 5 by both.

## **Other Applications**



Fig.9 In irradiating packaged par with high-energy ion beams, different features in the package can result in ions with variable energy/LET reaching the SV.

increasingly sinks, metal lead frames, various epoxies or other fillers and even other die in Systems In Packages. True 3-dimensional monolithic silicon parts, such as 3D NAND Flash memory, are also becoming more complex and possibly less homogeneous.

Additional applications can be found by taking advantage of the concept of volume equivalent LET,  $LET_{EO}$  [12,13]. An ion's  $LET_{EO}$  is defined in terms of the deposited energy  $E_{dep}$  in the SV, the SV depth d and the material density  $\rho$ 

$$ET_{EQ} = \frac{E_{dep}}{(\rho * d)}$$

In many cases, secondary particles (recoil ions, delta rays) may result in significantly higher and variable  $E_{den}$  for a small proportion of the ions (see Fig. 10).



Fig.10 This plot of charge deposited in a representative 2×2×2.25 μm SV for an SRAM from [14] shows that while most events deposit charge/energy consisten with the particles' low LET, some ions generate secondaries in high-Z elements ir the die or packaging, resulting in nonzero

probability of much higher  $LET_{EO}$ .

Secondary particles can have a significant effect on the cross section especially when the primary ion LET is at or below threshold. A conventional fit to  $\sigma$  vs. LET would be forced incorrectly to choose very low onset LET, whereas use of a  $LET_{EO}$  distribution allows the  $\sigma$  averaged across the distribution to be nonzero even for ion LET below threshold. A similar situation occurs with generation of rare delta rays [15] significantly augmenting the energy deposited in some small SV, especially for very high-energy ions. While such events render use of LET questionable for high-energy ion energy deposition in deep submicron parts, the situation may prove amenable to fitting with use of  $LET_{FO}$  distribution.

Unfortunately, having the capacity to fit  $\sigma$  vs.  $LET_{FO}$  for situations where secondaries are important does not mean that one will have sufficient information to do so. For instance, although high-energy protons generate SEE via p + Si recoil ions with Z from 2-15, and LET up to ~15 MeVcm2/mg, for protons energies (E<sub>n</sub>) between 20 and 500 MeV, over 90% of the ions produced have  $LET_{EO}$  well under ~5.5 MeVcm<sup>2</sup>/mg (for a 1  $\mu$ m cube), and the total cross section for ions with  $LET_{EQ} > 0.5$  MeVcm<sup>2</sup>/mg varies by only a factor of 2 over this proton energy range). Also, for common proton energies ( $50 < E_p < 500$  MeV) the proton recoil  $LET_{EQ}$  spectrum varies so little that it is not possible to build a piecewise picture of how  $\sigma$  varies with LET as in Fig. 8. Testing with variable proton energy mainly produces recoil ions over the same narrow range of  $LET_{EQ}$  (see Fig. 11). Although it is possible that the greater sensitivity of high-Z nuclear reactions could better cover the needed LET spectrum the reaction products are still low-energy, and daughter products of most materials show little dependence on primary energy.



Many other situations occur where the ion LET responsible for an SEE is uncertain. These include daughter products of nuclear reactions [3], which could prove amenable to treatment using  $LET_{FO}$ , and even anomalies in the space environment itself, where event rates in various environments (e. g. solar particle events, the South Atlantic Anomaly, etc) can yield insight into device responsible. Indeed, if a program is using large numbers of devices with different sensitivities, changes in the relative rates for such devices could provide insight into the particle content of these different environments.



## Conclusions

We have modified the SEE  $\sigma$  vs. LET fitting procedure from [7] to deal with situations where LET is uncertain by replacing point estimates of  $\sigma$  with averages of over the expected LET distribution. A detailed example discusses backside irradiation of a thinned DDR SDRAM, with variable overburden over various device SV. In this example, while use of  $\sigma$  point estimates does not prevent the fit converging as event count increases, it introduces a systematic error with magnitude depending not just on the range of LET uncertainty, but also on the behavior of  $\sigma$  vs. LET over that range. By revealing general dependence of the resulting systematic error, the analysis also yields general principles useful for minimizing systematic error even if the precise LET distribution is not known. The procedure is likely to also be useful when inhomogeneous materials in 3-dimensional packaged microcircuits result in uncertain LET under irradiation with highenergy, penetrating heavy ions.

However, uncertain LET occurs in a variety of other applications, including those where secondary particles contribute significantly to energy deposition in some events, such as proton-recoil ions, nuclear reactions and the production of delta rays especially by very high-energy ions. These problems could also be treated with the approach discussed here using the volume equivalent LET, rather than ion LET.

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